SOFTWARE LICENSE AGREEMENT

	into Vaterloo, Ontario, N2L 5B	, 2003 between Siborg Systems Inc. , residing at 24	
		("Licensee"	').
1. Definitions			
	to which Licensor has all	in Attachment A annexed hereto and incorporated herein, who is rights and includes any and all versions, updates, enhancementated thereto.	
1.2 Computers mean the	computers on which the S	Software will be used, namely	. •
1.3 Location means the lo	ocation at which the Com	puter is located, namely	
2. Grant of License			
2.1 Licensor grants to Licensor on the Computers , at the		nd non-transferable license to exploit copies of the Softw	are
		applied "as is", without any accompanying maintenance service icensor assume any responsibility resulted from the use of the	
2.3 Licensee acknowledg	es that the Software will l	be used only for educational and research purposes.	
3. Confidentiality			
		onfidential by Licensee and are not to be transferred or allowe written permission from the Licensor .	d to
	-	caused this Agreement to be executed by their duly authorized ay and year first above written.	and
Licensor (Siborg System	s Inc.)	Licensee	
Ву		Ву	
ATTACHMENT A (Soft			
The Software is the softw	ware tool package MicroT e operates under Windows	Cec for two-dimensional semiconductor process and device s on any IBM-PC/AT486 or higher. It requires not less than 1	
2. SemSim : a program for		n of implantation, diffusion and oxidation. sional semiconductor device simulation. m .	
	r two- and three-dimensio grating the programs here		
ATTACHMENT B (Spec	ification of the Comput	er(s))	
Computer type PC-AT/	486 o Pentium o Pentium	I-II o Pentium-III o Pentium-IV o Other	
Memory available	Mbytes		
Videocard			
Printer Operating system	vorsion		
COCLAIMS SYSTEM	VELSIOH		